

# Degradation and electric behavior in thin film photovoltaic devices

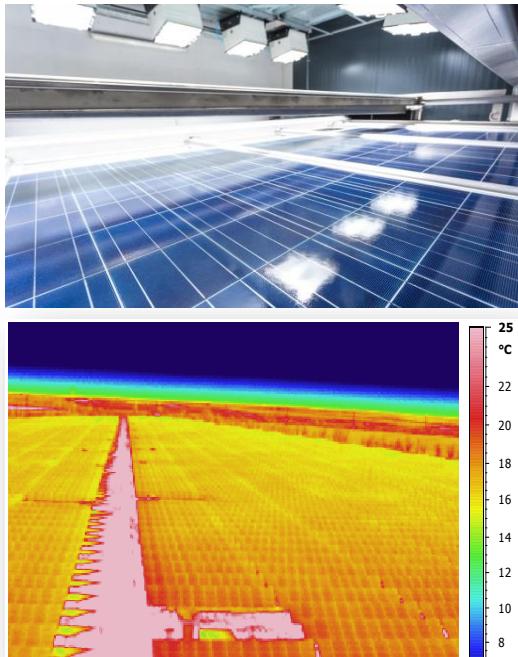
Marcus Rennhofer ([marcus.rennhofer@ait.ac.at](mailto:marcus.rennhofer@ait.ac.at))

# Content

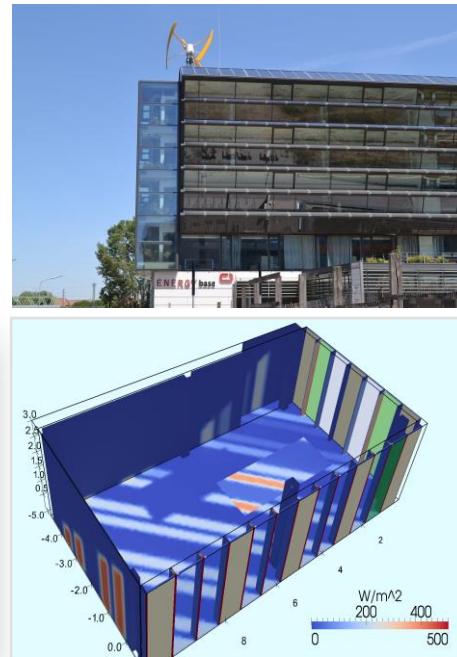
- Photovoltaic Systems at AIT
- Characterization on cell level
- Characterization on module level
- Characterization vs. Degradation

# Photovoltaic Systems at AIT

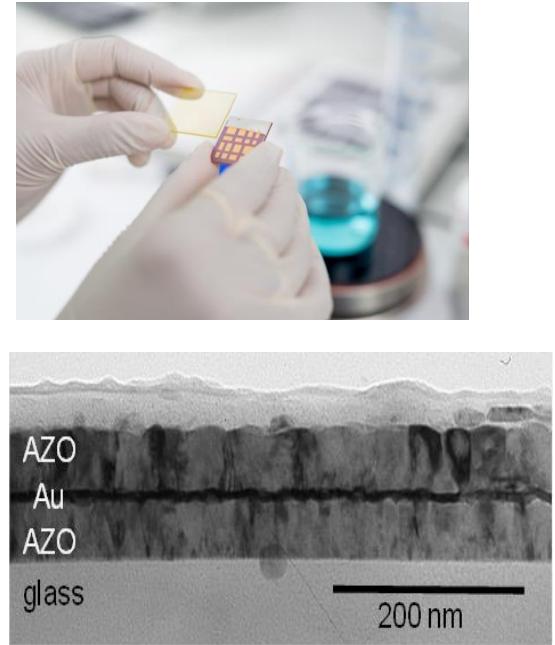
Assured quality for solar power systems and components



Building-integrated photovoltaics - BIPV



Technologies for next-generation solar cells



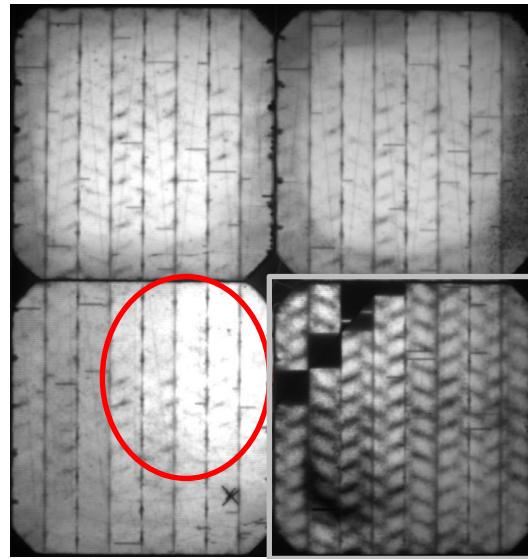
# 1. Electro-optical Characterization on Cell Level

Comparison of different methods for optical characterisation of PV Cells and mini-modules within CHEETAH

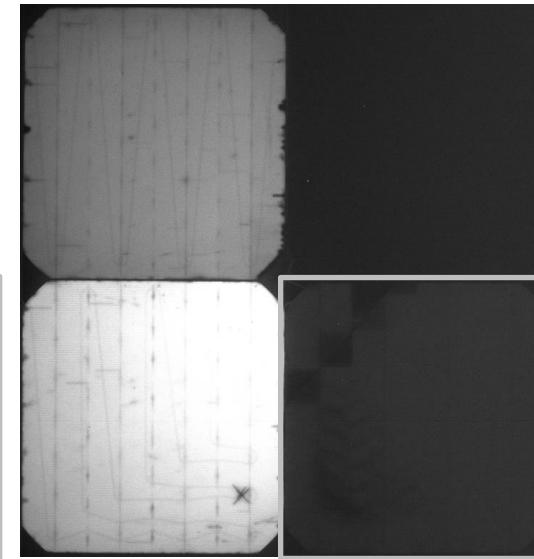
- Electroluminescence (EL):      100% Isc and 10% Isc
- Photoluminescence (PL):      NIR: 840 nm, 100W electrical power
- Photoluminescence (PL):      VIS: 525 nm, 4,8 kW electrical power
- Dark lock-in infrared thermography (DLIT):      100% Isc, 5s period,

## Electroluminescence 100% Isc, 10% Isc and DLIT

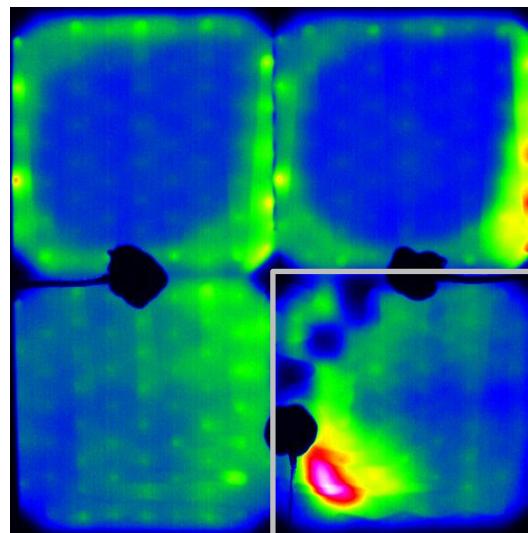
100% Isc



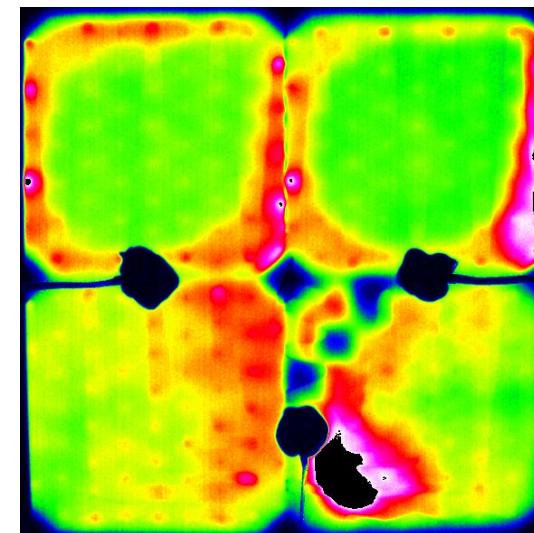
10 % Isc



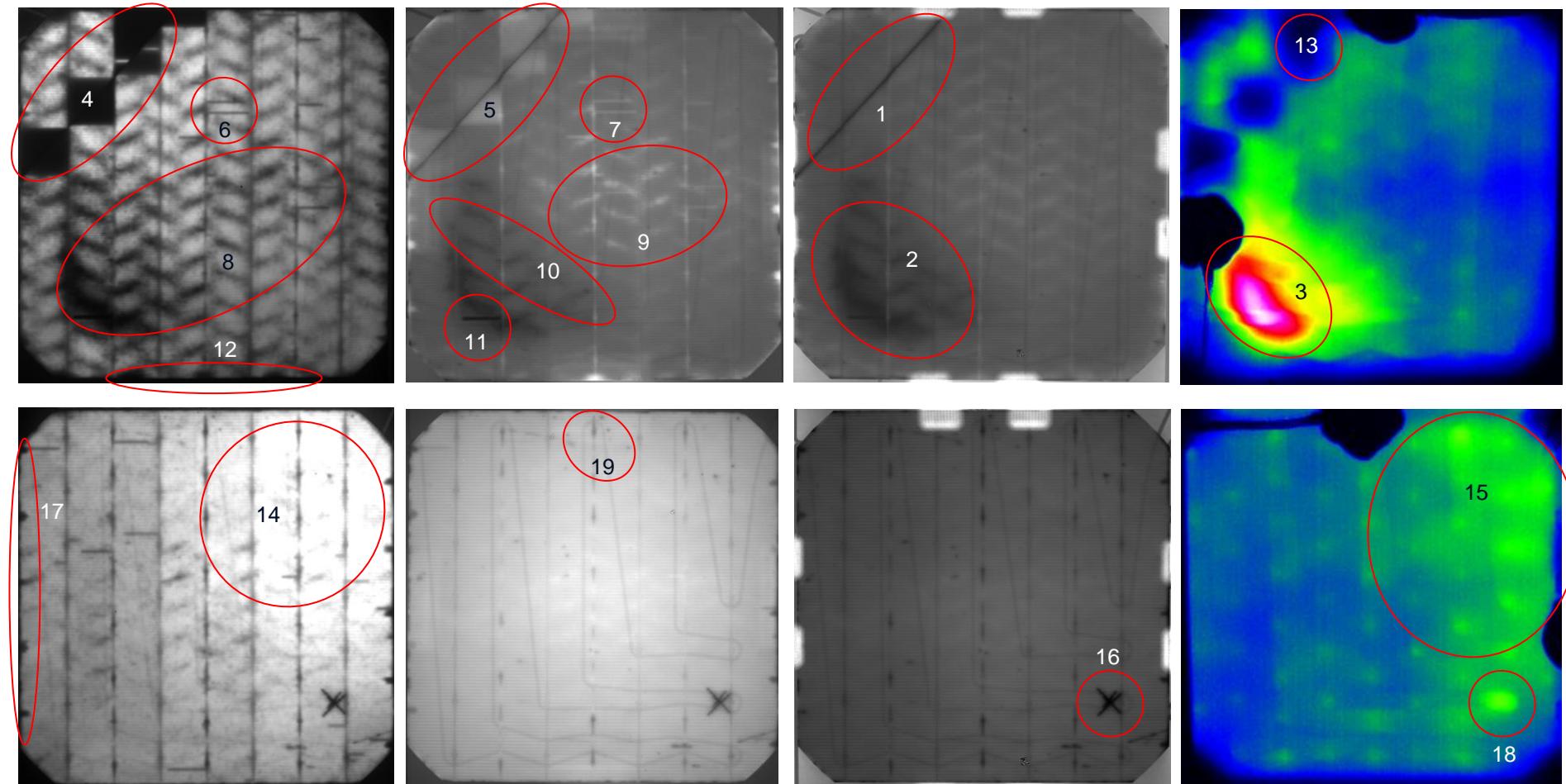
DLIT scale 0-100%



DLIT  
scale 0-65%



# EL100% Isc, PL NIR 840nm, PL VIS 525nm and DLIT



EL 100% Isc

PL 840nm

PL 525nm

DLIT 100% scale

## Defects of cells

- 1 - **Microcrack**
- 2 - **Shunt**, low parallel resistance in the cell
- 3 - **Hot spot** due to shunt in the cell
- 4 - Electrically **separated regions** of the cell (no electrical contact)
- 5 - Electrically separated regions of the cell operate in open circuit mode
- 6 - **Fingers interrupted**
- 7 - Interrupted fingers **operate in open circuit mode**
- 8 - **Oven imprints**
- 9 - Oven imprints operate in open circuit mode
- 10 - Oven imprints **operate in short circuit mode**
- 11 – Interrupted finger operates in short circuit mode
- 12 – **Insulation problems** on the edge of the cell
- 13 – **Missing electrical contact**

## Defects of cells

- 14 – **High current density** due to bad contacts someplace else
- 15 – **Hot contacts**
- 16 – Microcracks
- 17 - Insulation problems on the edge of the cell
- 18 – Hot spot due to soldering problem
- 19 – **Small shunts**

# Methods: Advantages - Disadvantages

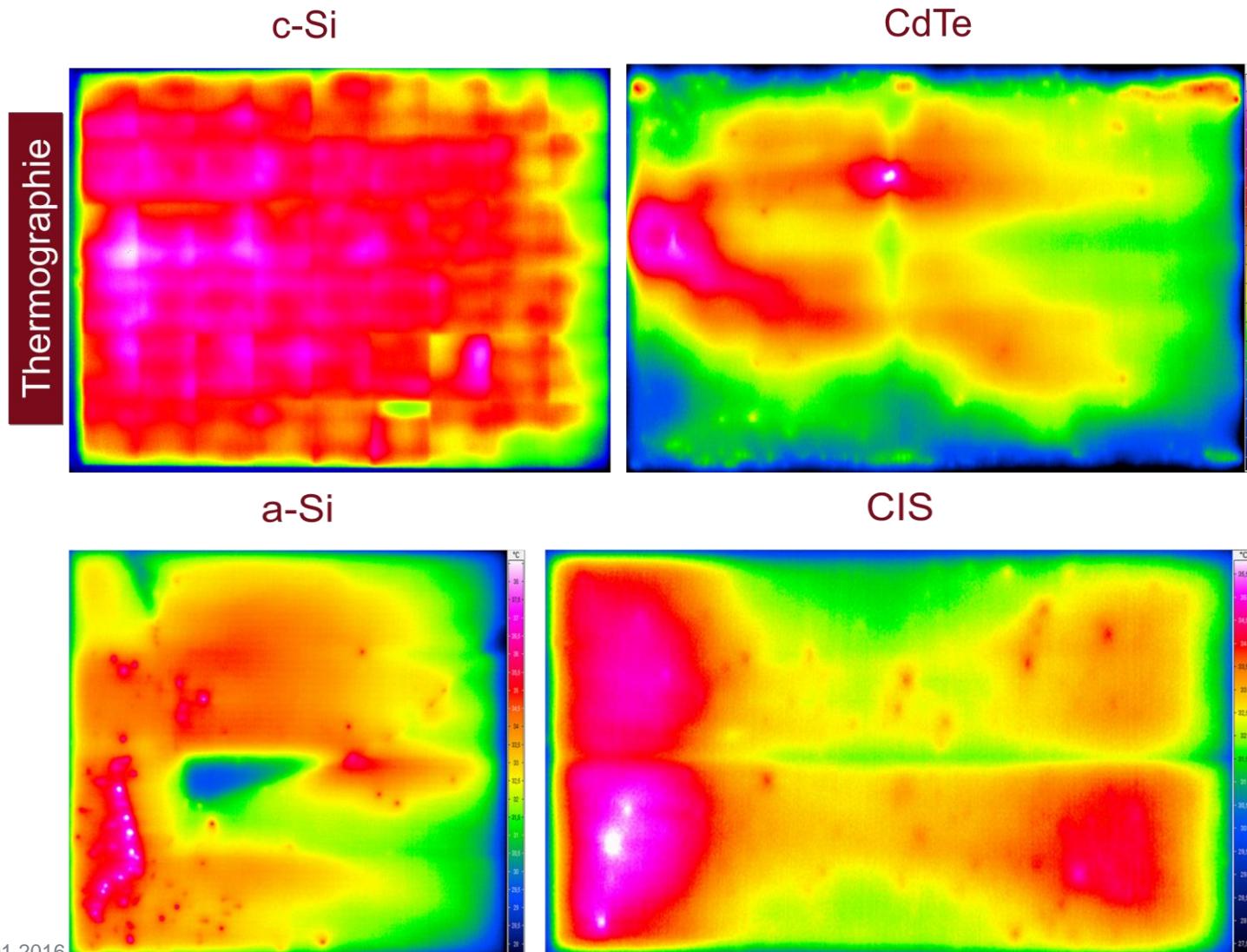


- EL:  
electrical contact defects,  
cracks, cell crystalline defects,  
short circuited cells
  
- PHL:  
no electrical contacts needed  
all type of cracks detectable,  
fast method,  
cell crystalline defects,  
bottom of the cell visible
  
- DLIT:  
electrical contact defects,  
big crystalline defects,  
displays soldering faults, can  
differentiate between „hot“ and  
„cold“ contacts  
good resolution for shunts

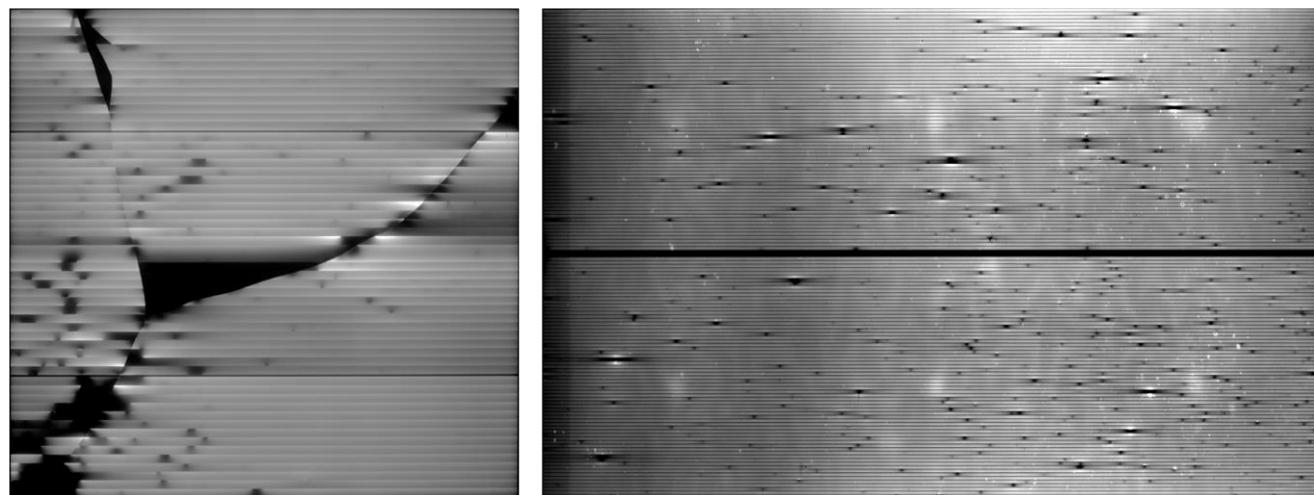
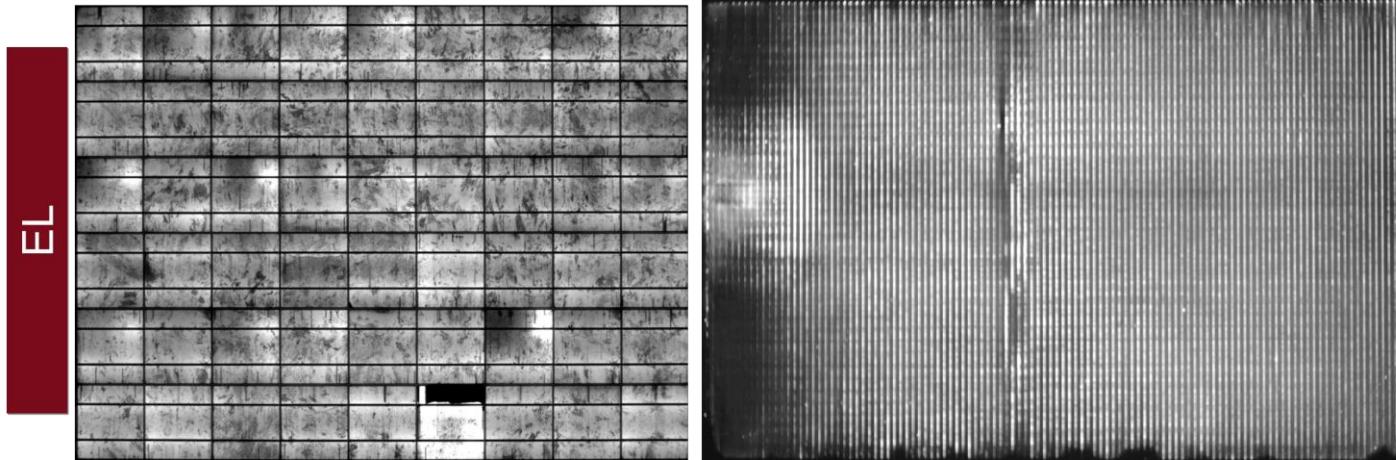


- not all cracks detectable,  
electrical contacts needed,  
electrically not contacted regions often  
not measurable
  
- can not differentiate between „hot“ and  
„cold“ electrical contacts,  
electrical contact defects between cell  
and busbar not detectable
  
- can not detect cracks and small  
crystalline defects,  
slow method,  
reflection problems,  
electrical contact needed

## 2. Electro-optical Characterization on Module

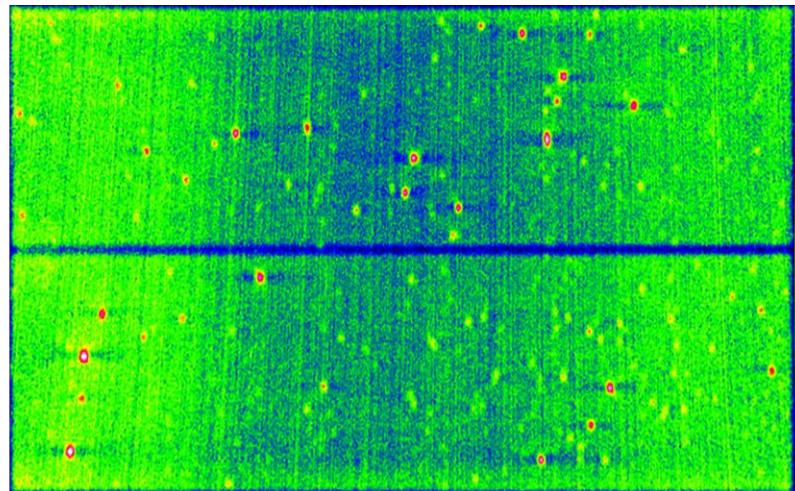
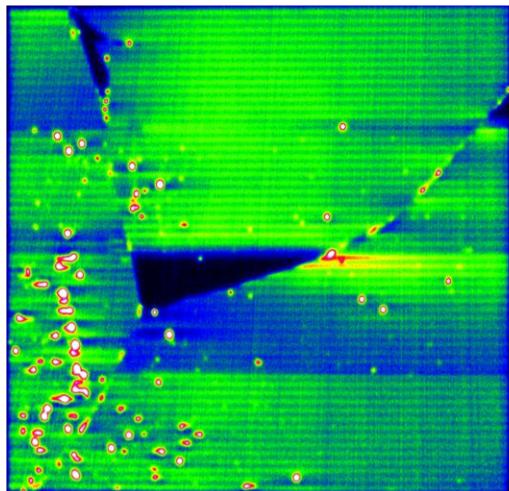
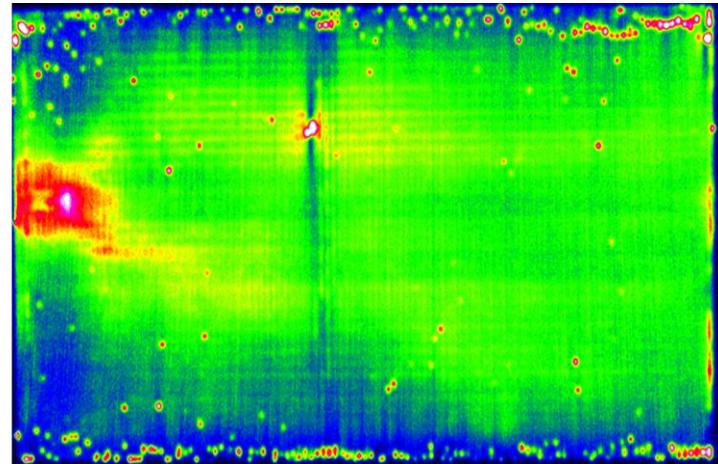
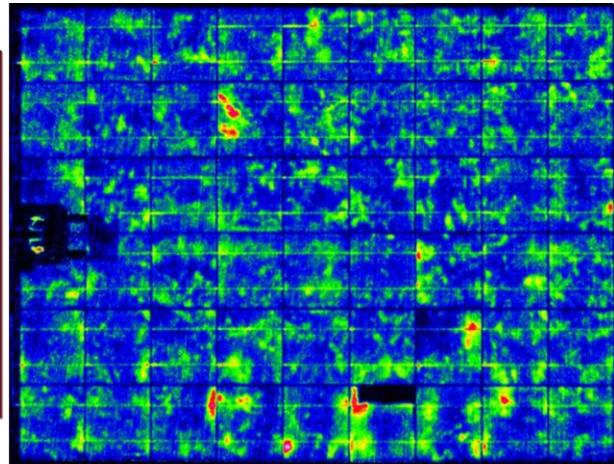


# Module Level: Electroluminescence



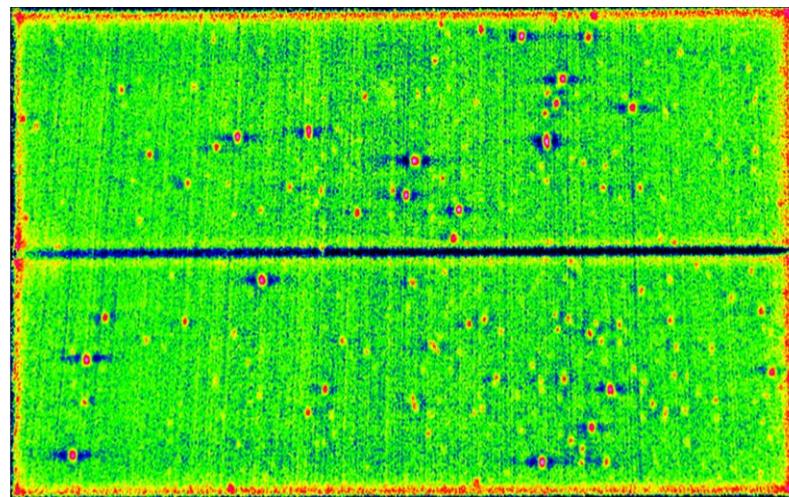
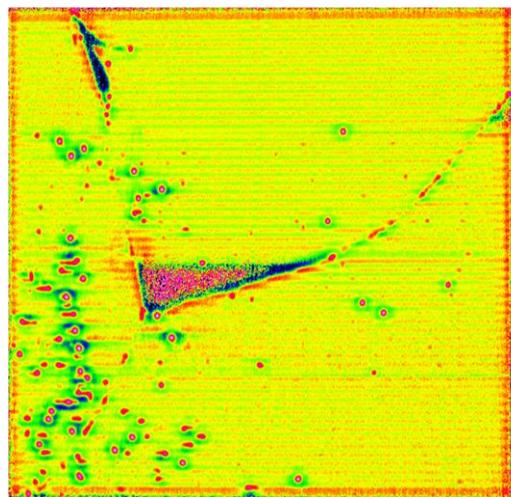
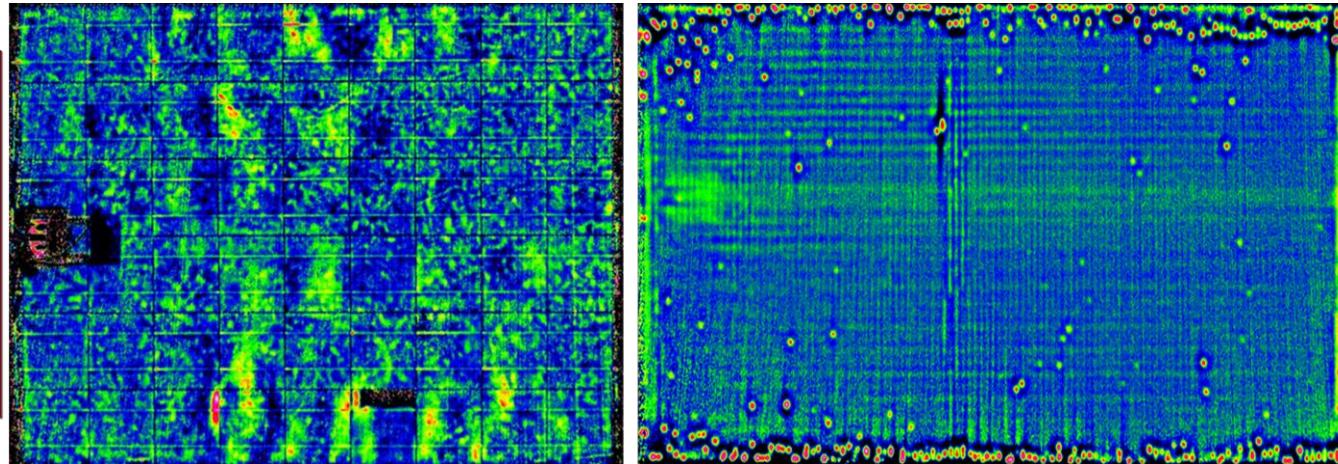
## Module Level: DLIT-Amplitude

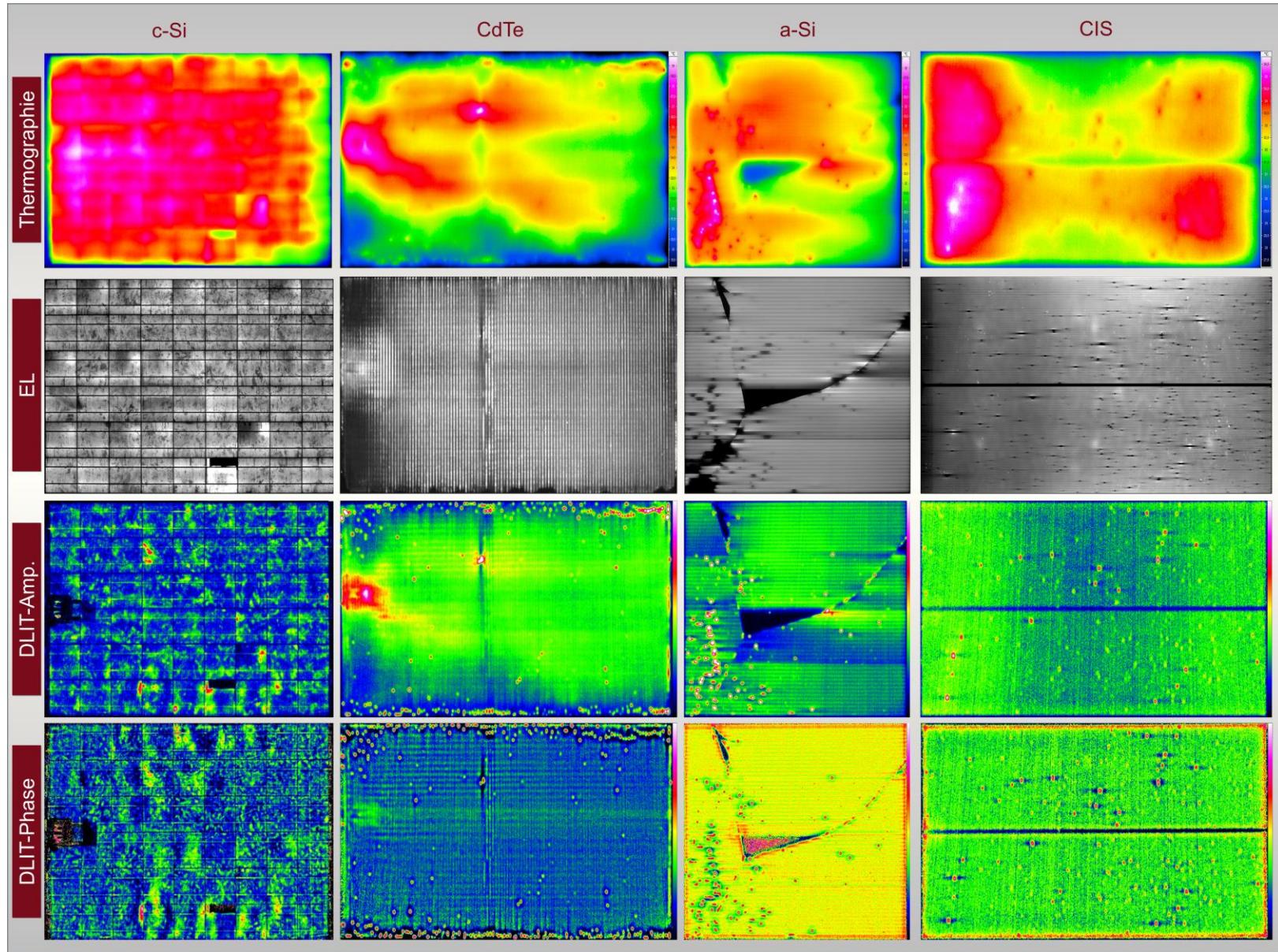
DLIT-Amp.



# Module Level: DLIT: Phase

DLIT-Phase

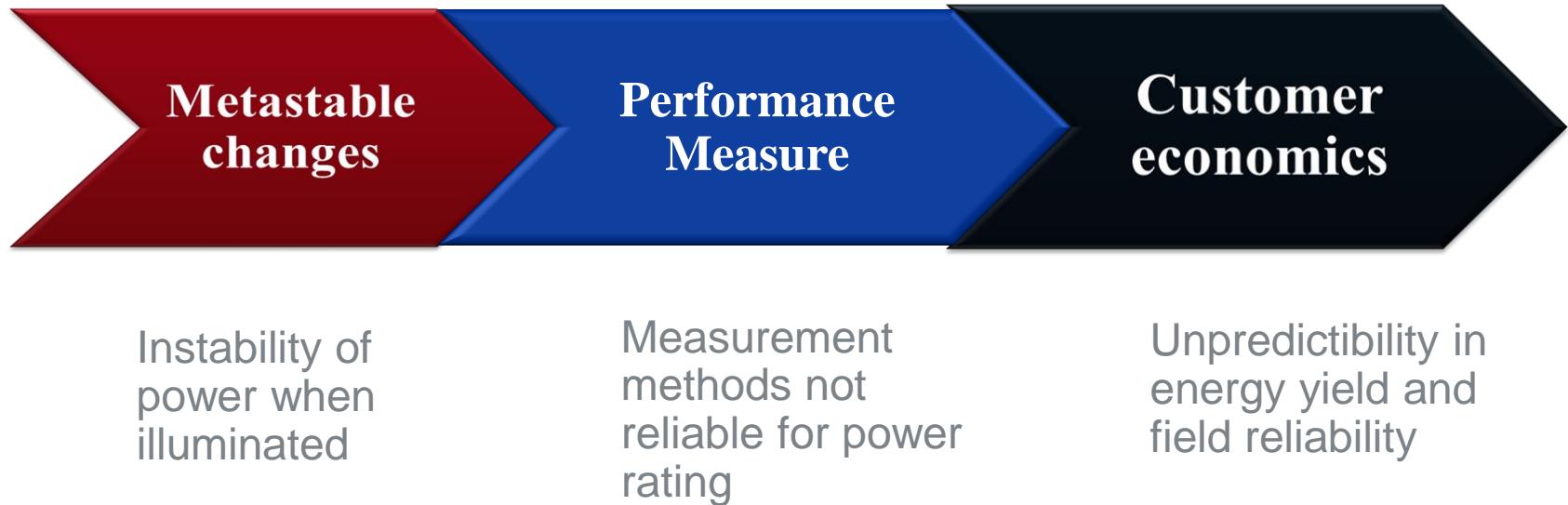




## 2. Electrical characterization vs. Degradation

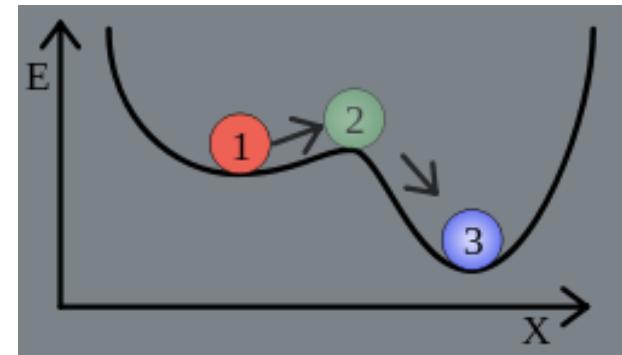
Thin Film module affected by unstable behavior under illumination

Why metastable behavior affects PV community?



# Metastabilities in Thin-Film Technologies

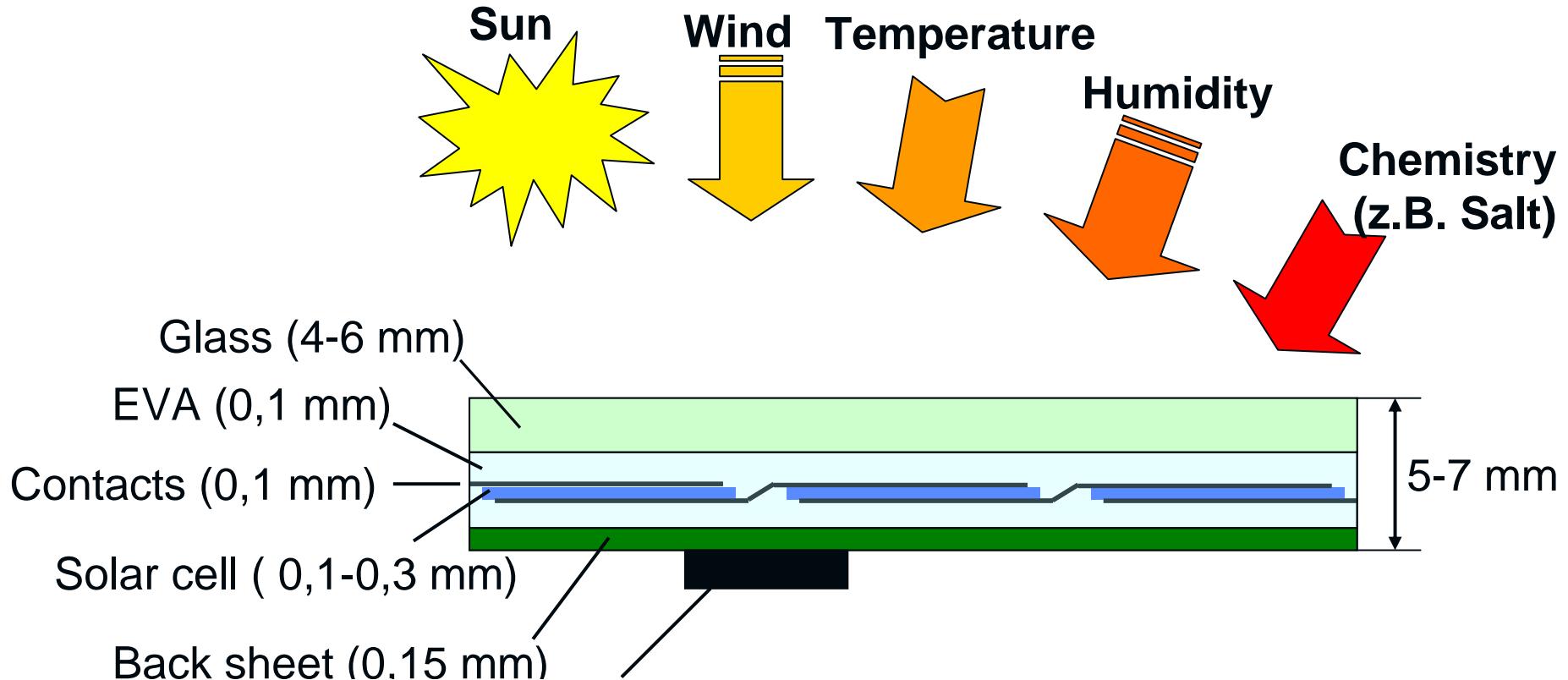
- A non-ground state (e.g. triggered by light)
- Metastable states may relax, e.g. thermally driven
- Origins from defect structure in the device
- Study on device level



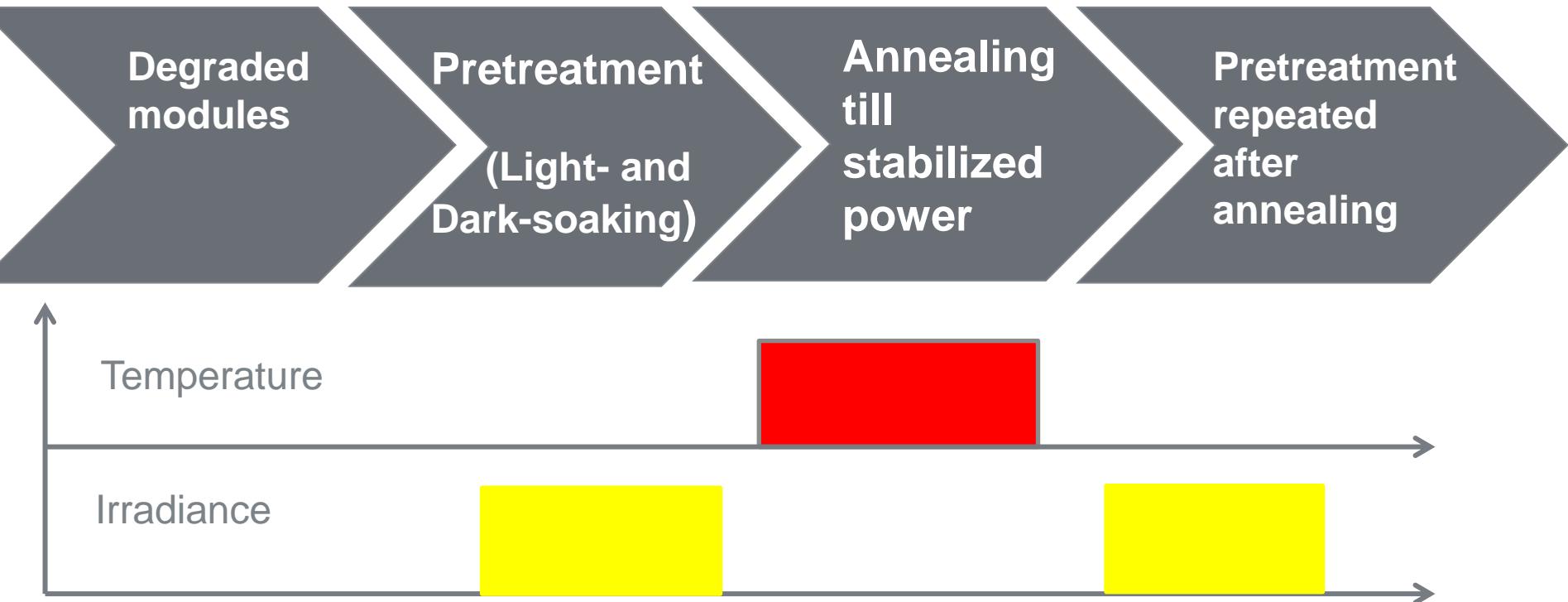
Metastabilities found in all thin-film devices:

a-Si, a-Si/ $\mu$ Si, CdTe, CIS, CIGS, CZTS, OPV, Perovskite

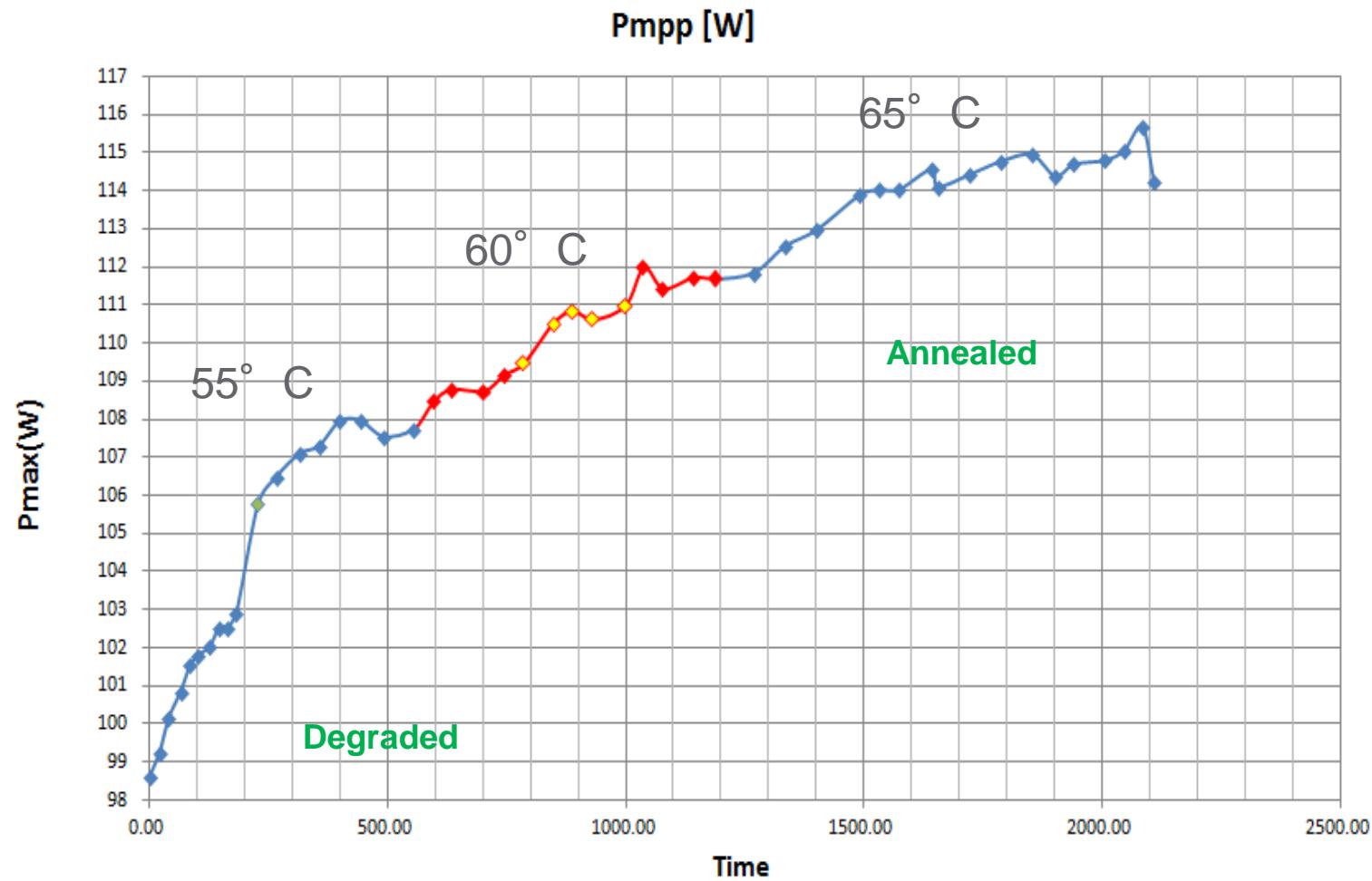
# Degradation influences metastable behavior



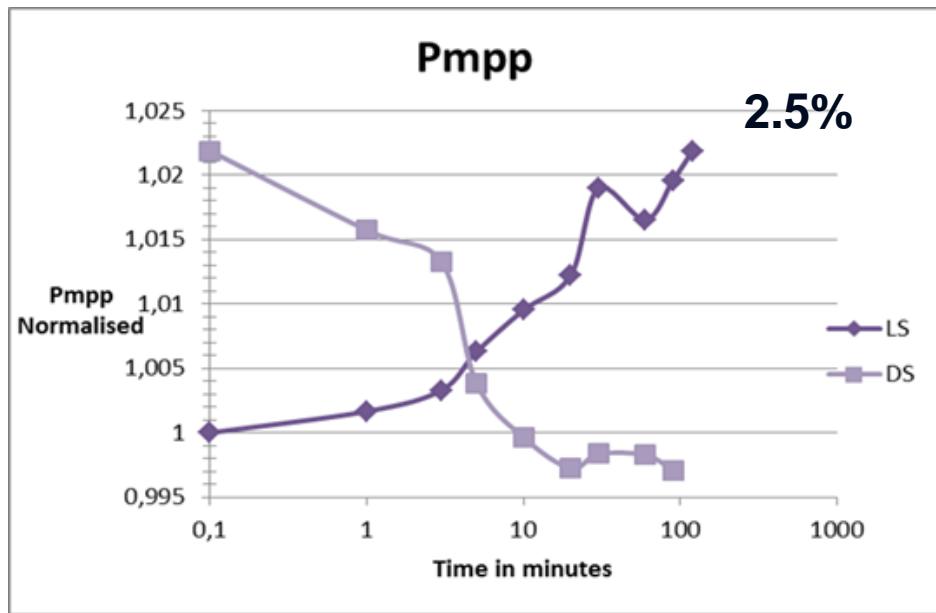
## Pre-Treatment Procedure a-Si



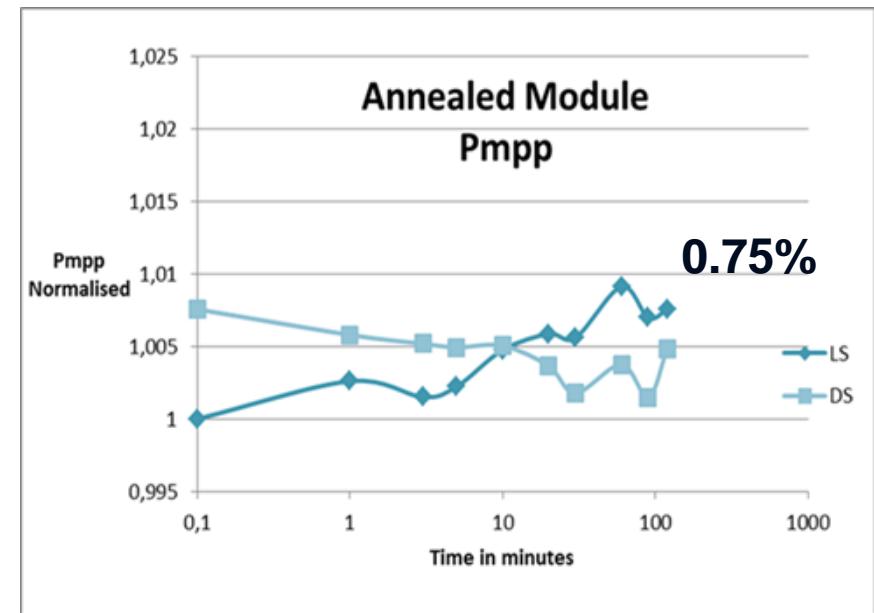
# Annealing of a-Si



# Metastable Behavior a-Si before and after annealing

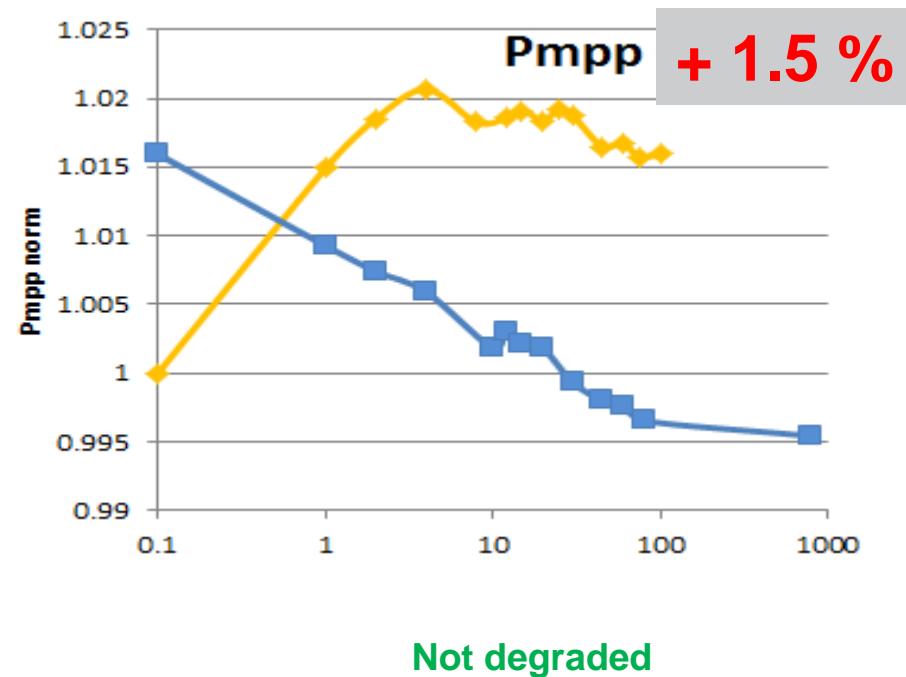
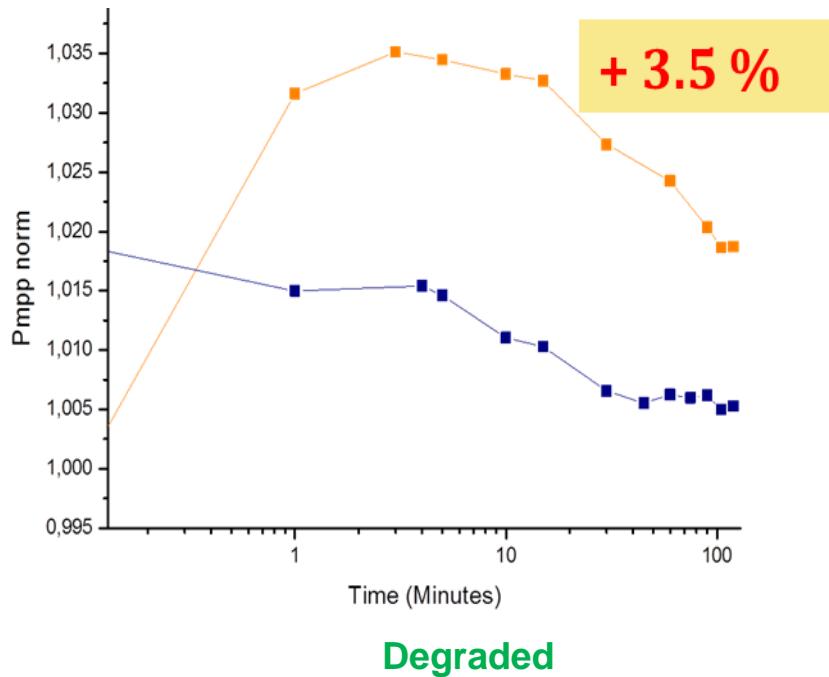


Degraded

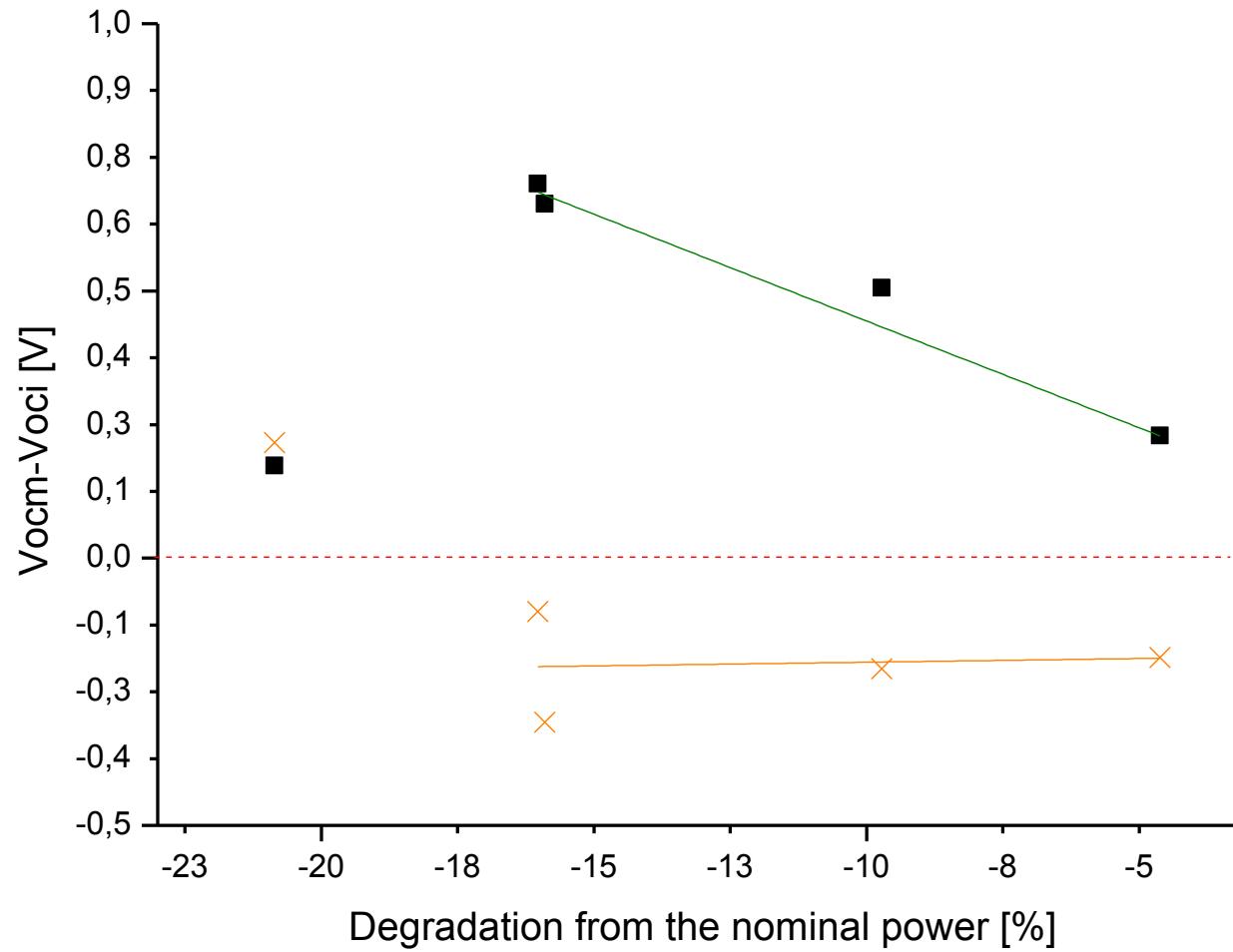


Annealed

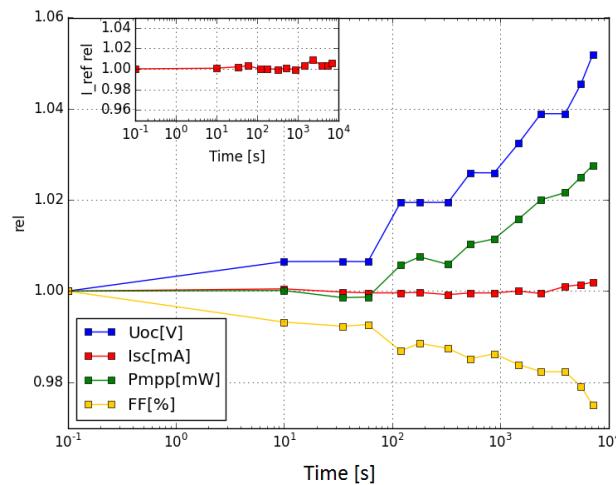
# Metastable Behavior CdTe before and after degradation



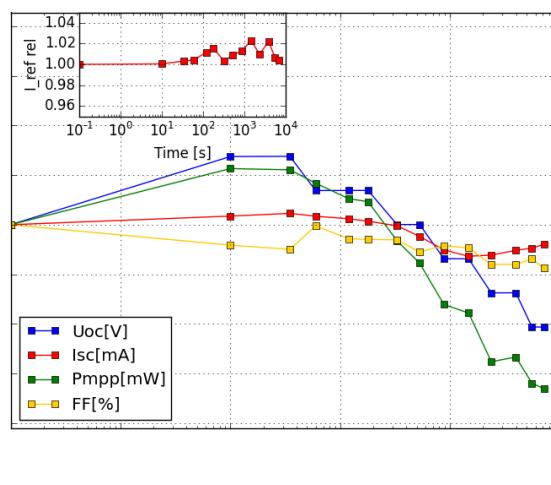
## Dependency on degradation CdTe



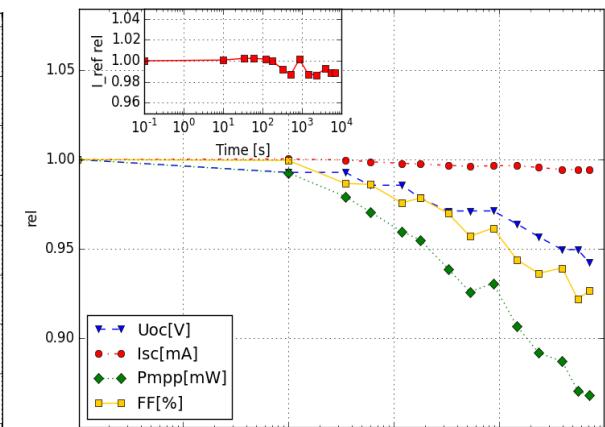
# Metastable Behavior CIGS dependent on cell quality



worst

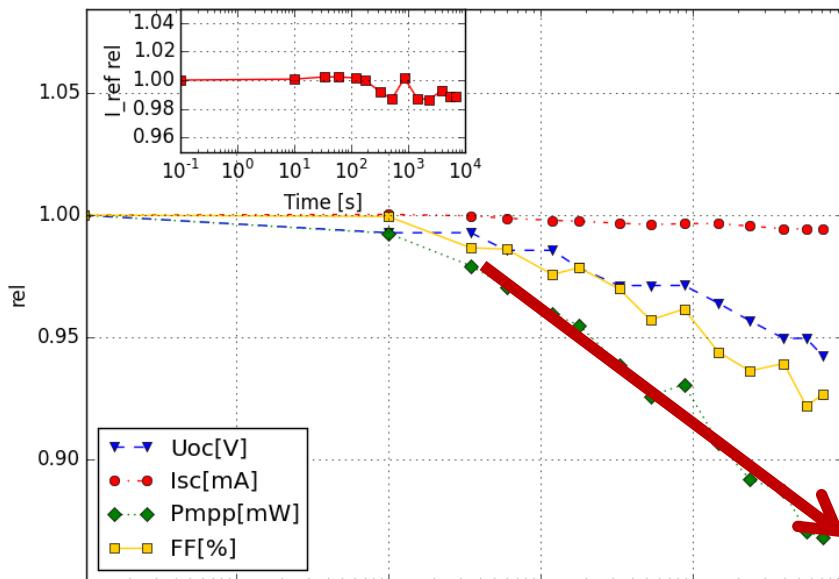


medium

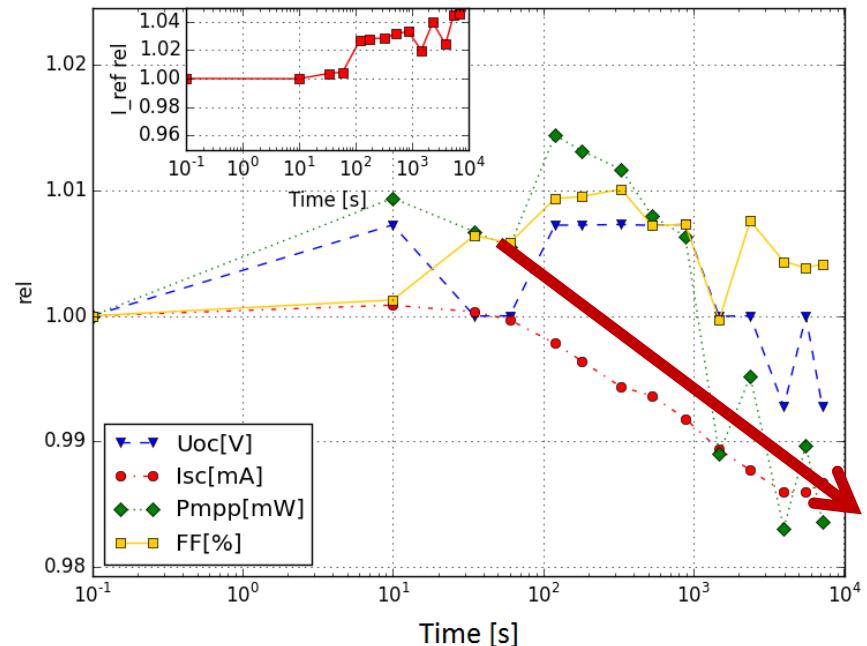


best

# CdS vs. ZnO buffer: CIGS



CdS: best



ZnO: best

# Acknowledgement

- AIT - Shokufeh Zamini, Ankit Mittal, Daniel Menz, Bernhard Kubicek, Gustav Ujavari, Roman Leidl
- University of Vienna - Dr. Viktor Schlosser, Dr. Wolfgang Lang
- TU-Vienna - Dr. Summhammer

# AIT Austrian Institute of Technology

your ingenious partner

Marcus Rennhofer ([marcus.rennhofer@ait.ac.at](mailto:marcus.rennhofer@ait.ac.at))